

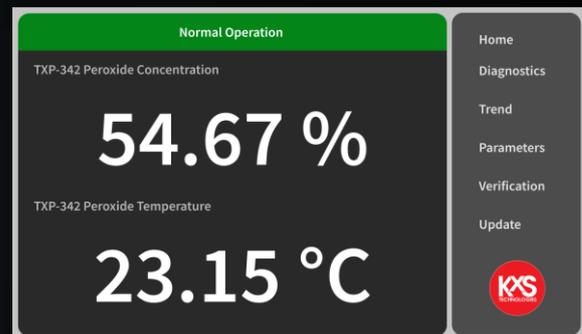
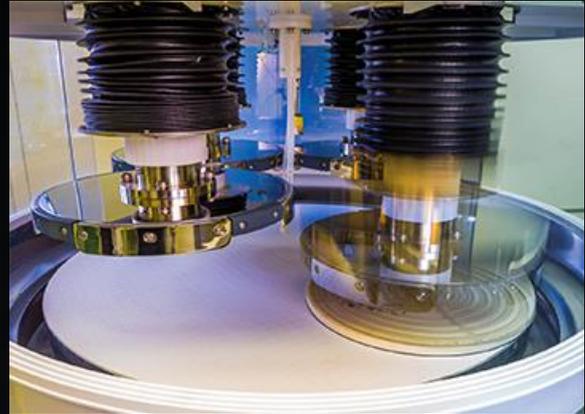
**DCM-10**  
INLINE CONCENTRATION MONITOR  
FOR CRITICAL FAB WET CHEMICALS



# APPLICATIONS

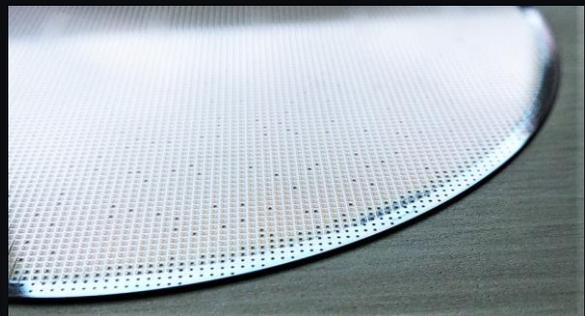
DCM-10 optical concentration monitor is designed to:

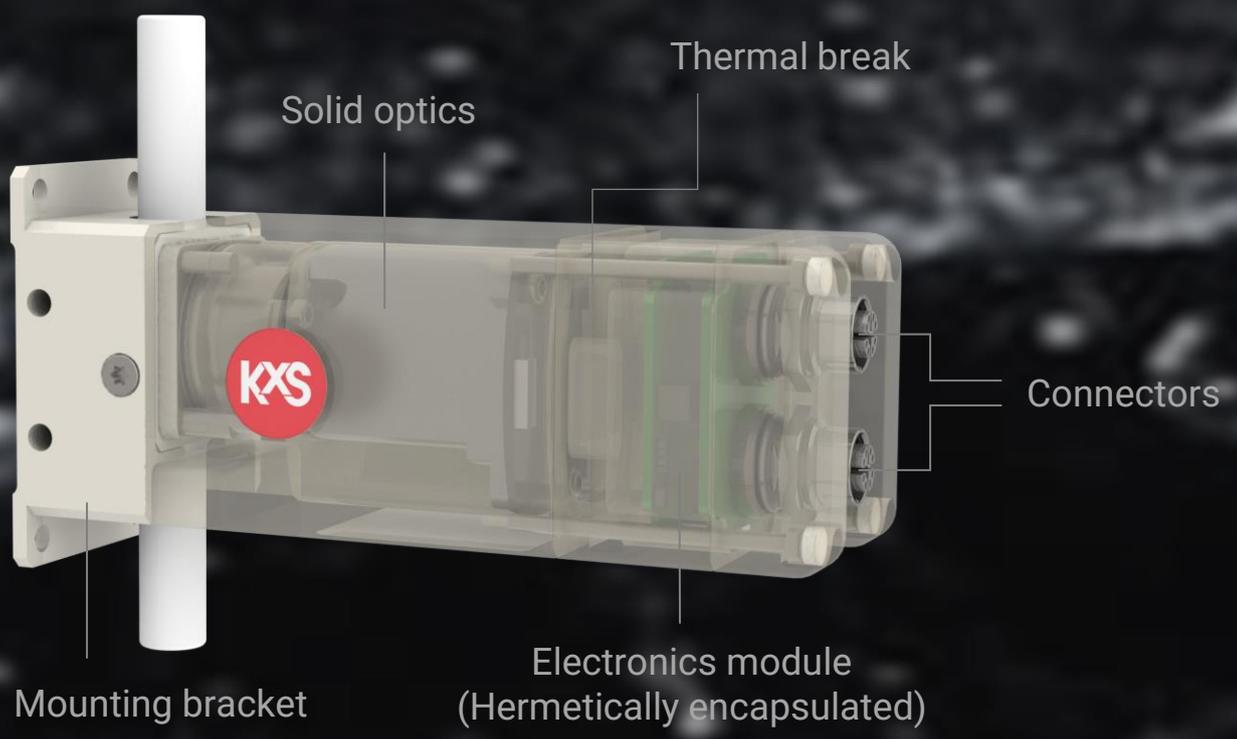
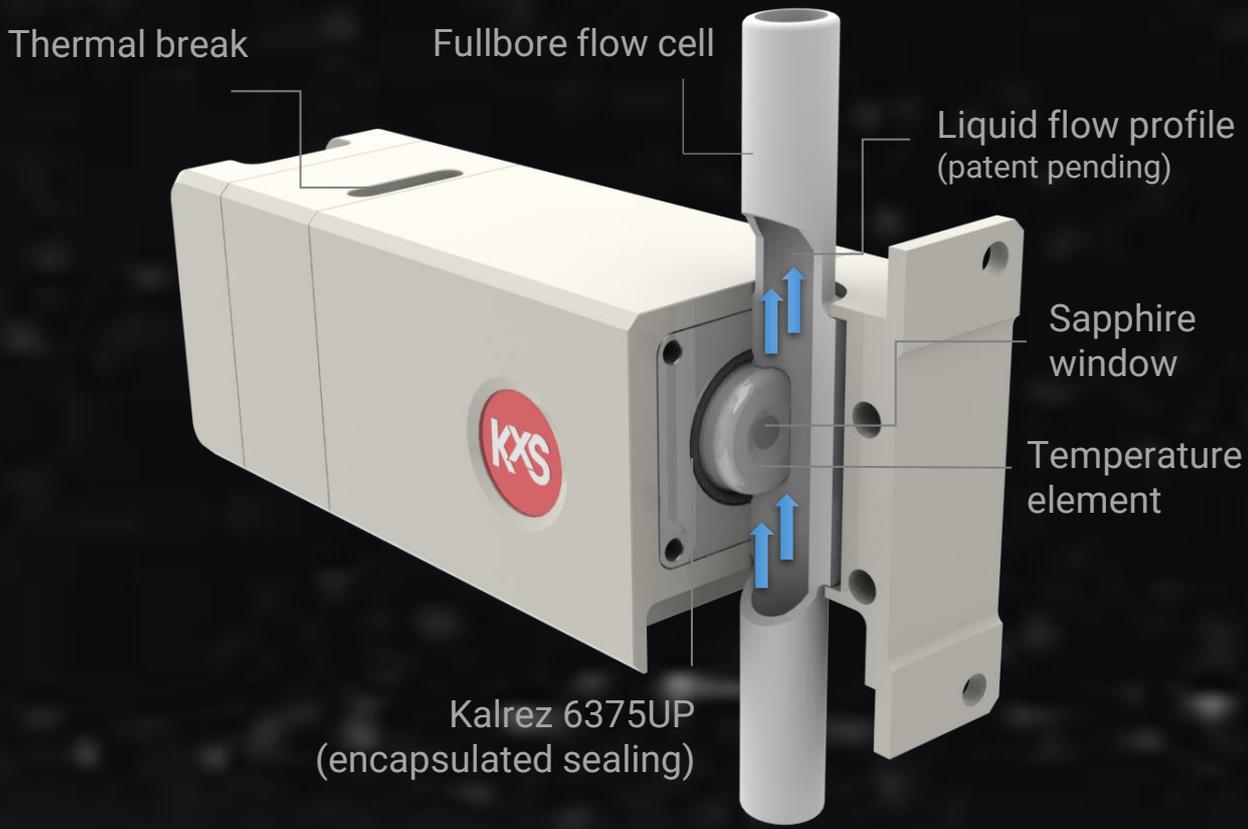
- **Define** incoming clean chemical and raw CMP slurry density
- **Achieve and ensure**  $H_2O_2$  conc% in CMP slurries for copper, tungsten and interlayer dielectric applications
- **Correlate** etch rate ER in e.g. wafer back side poly etch  $HNO_3:HF$  and buffered oxide etch BOE
- **Optimize** bath life of post-etch residue removers like EKC265™ and other solvents in wet strip spinning tools



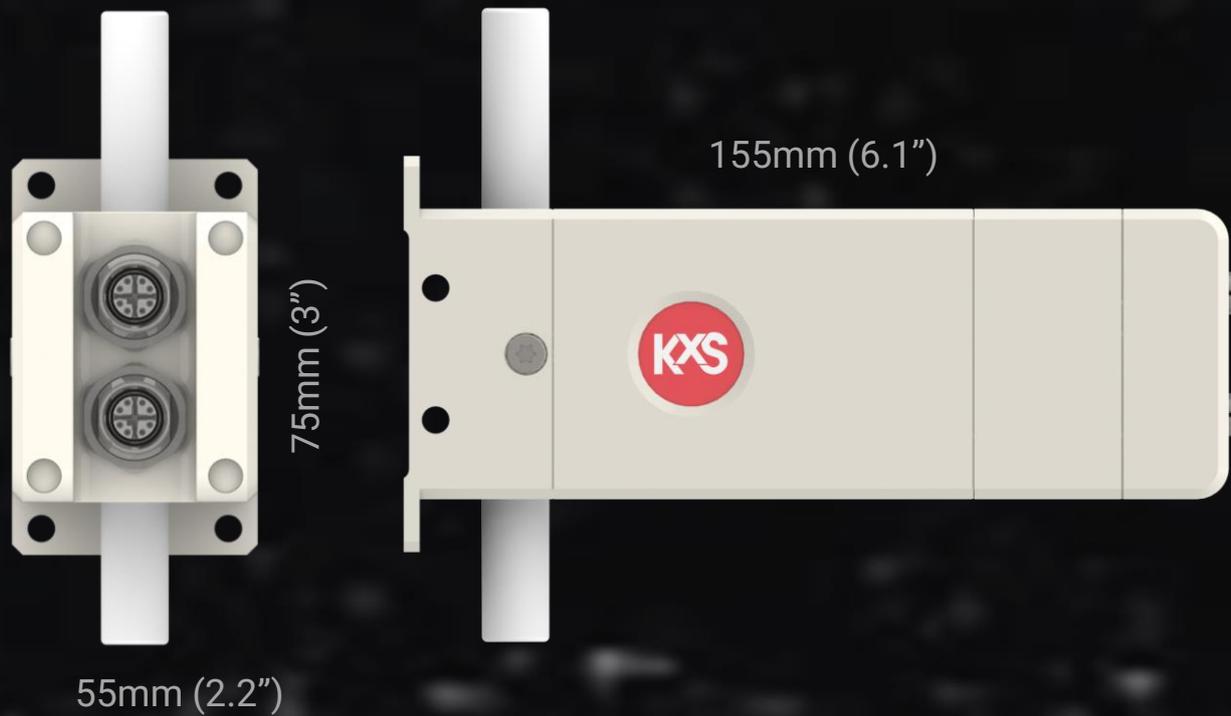
## Other typical application uses:

- Chemical feed and blend verification of SC-1 and SC-2
- Silicon wet etch with 50% KOH
- Titanium etch with  $H_2SO_4:HNO_3:H_3PO_4$  blends
- Post-CMP cleans with various mixtures

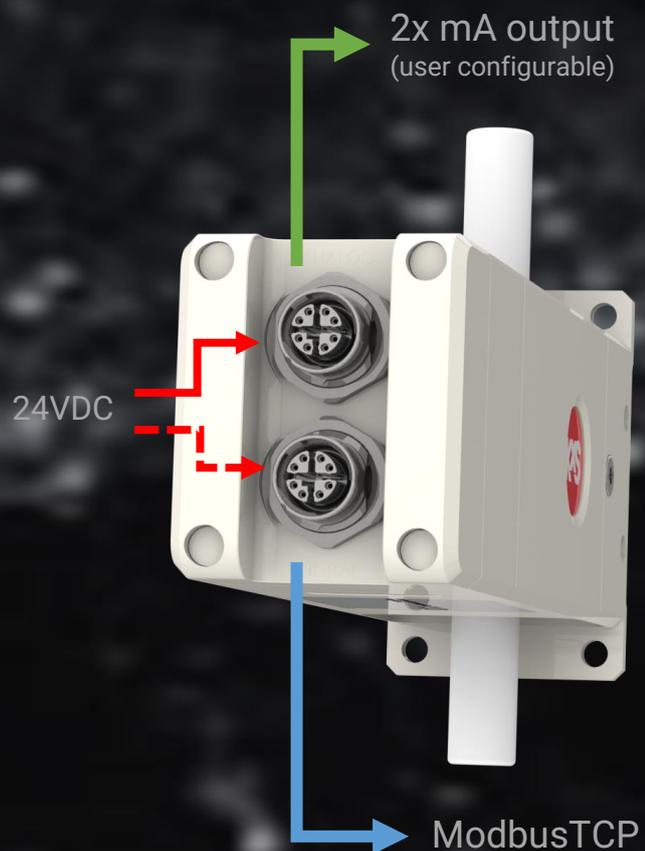




# ¼" .. 1" Full bore flow cells for Flare, Pillar, PrimeLock® connections

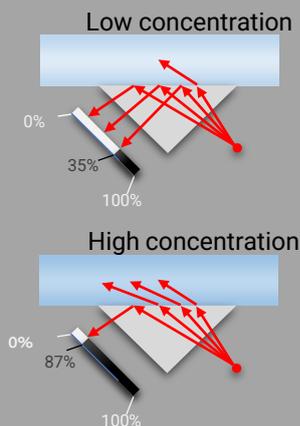


## Digital and analog M12 connectors

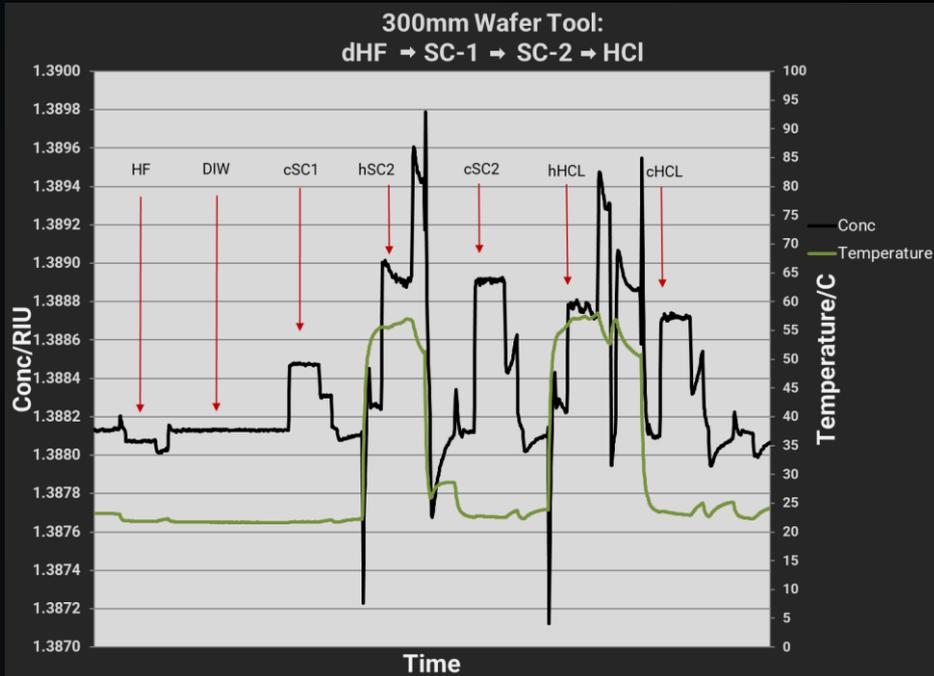


## Measurement principle

The optical concentration measurement is based on *Snell's law* and *critical angle of total reflection*. Light is transmitted from the LED to the interface between the optical window and the liquid. With the concentration of the liquid, defined angles are reflected back creating light and shadow interface images on the digital camera. The interface of the light activated pixels is converted to refractive index units and concentration values.

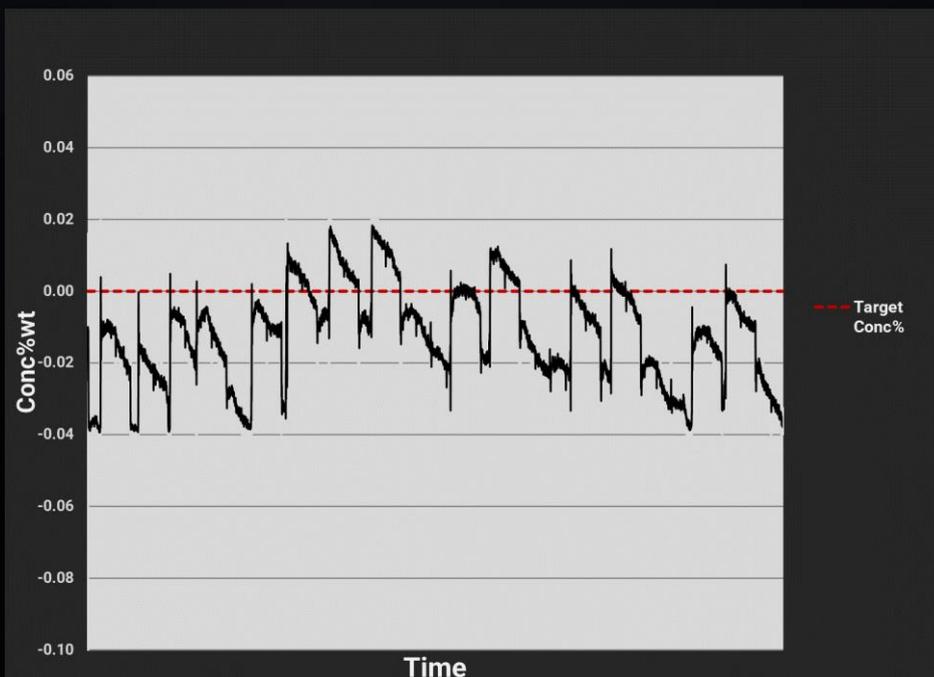


# ONE MOTIVATION: Reduce mix-to-mix and chamber-to-chamber variability



## Distinct interface detection of

- dilute HF
- DIW flush
- cold SC-1
- hot SC-2
- cold SC-2
- hot HCl
- cold HCl



## Chemical spiking and dispense

- H<sub>2</sub>O<sub>2</sub> in CMP slurries
- H<sub>2</sub>O<sub>2</sub> NH<sub>3</sub> water and HCl in tool in-situ blending

# DCM-10 concentration monitor specifications

Refractive Index range, standard:	Full range, nD=1.3200...1.5300 (equival by definition to 0...100%wt)
Output units:	RIU (refractive index unit) / Conc% / g/cm <sup>3</sup>
Measurement precision:	± 0.025 %wt
Speed of response:	1s undamped
Optics:	No mechanical adjustments and digital measurement with 4K camera element, 589 nm wavelength (sodium D-line) light emitting diode (LED), built-in Pt-1000 (1/3B) temp sensor (linearization according to IEC 751)
Temperature compensation:	Automatic, individual zero point calibration
Calibration:	NIST traceable calibration, verification with standard RI liquids
Wetted parts:	PFA, Sapphire, ECTFE Encapsulated sealing: Kalrez 6375UP o-ring Sensor housing: polypropylene(PP)
Process connection:	Standard tube ends for Flare, Pillar Type or PrimeLock® Tube sizes: ¼", ⅜", ½", ¾" or 1"
Process temperature:	0°C (-4°F)...85°C (185°F)
Ambient temperature:	0°C (-4°F)...45°C (113°F)
Sensor protection class:	IP67, Nema 4X
Sensor weight:	330g (11.6 oz)
<b>Outputs and connections:</b>	
Digital M12 connector:	24VDC power supply and Modbus TCP, conversion to other protocols with converter module, cable lengths 2-10m (6-33ft), max, 70m(230ft)
Analog M12 connector:	24VDC power supply and 2x independent 4-20mA outputs, normal cable length 10m(33ft), max, 200m(660ft). Max. load 1000 Ohm
Sensor power consumption:	max. 2.5W
Options:	Modular Connection Unit, 4", 7" or 15" HMI, full color touch screen interface Communication protocol converter: from Modbus TCP to Ethernet IP or Profinet

*We reserve the right to technical alterations*

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